

# Survey of Materials

## Semiconductors

Andriy Zhugayevych

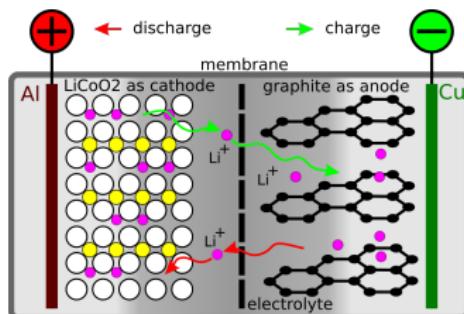
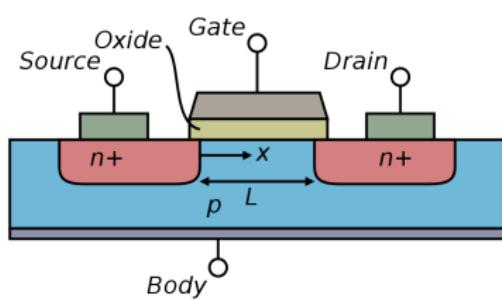
*October 8, 2021*

### *Outline*

- Introduction: definition and classification
- Key properties
- Applications: solar cells and field-effect transistors
- Classical semiconductors (1 slide)
- Perovskites (1 slide)
- Pnictides and chalcogenides (4 slides + optional slides)
- See separate lecture on organic semiconductors

# What is semiconductor: a functional electronic material

- Metals – passive electronic components (wires, electrodes)
- Insulators – passive electronic components (insulators)
- **Semiconductors** – active electronic components (device core)



**Electronic devices:** transistors, light emitters, solar cells, sensors – any device generating or transforming electronic current

**Passive electronic components** in devices with electronic-ionic current, such as cathode/anode in rechargeable metal-ion batteries

## What is semiconductor: definition by bandgap/conductivity

bandgap	class	electronic conductivity
several eV	insulators	no current because of self-localization
few eV	semiconductors	conductivity is easy to modulate
close to zero	semimetals	overlapping bands $\Rightarrow$ similar to doped semiconductors
close to zero	strongly correlated	charge density fluctuations can close/open pseudogap
negative	simple metals	invariable conductivity due to large density of states at Fermi-level

# Classes of semiconductors

Participating electrons: *sp*, *p*, *spd* (inorganic), *π*, *πd* (organic)

The diagram illustrates the periodic table with various orbital shells labeled:

- valence shells**: Represented by a circle containing the first two columns (H, Li, Be).
- d-shell**: A horizontal row of elements from Sc to Cd.
- f-shell**: A horizontal row of elements from La to Hg.
- strong relativistic effects**: Elements Fr, Ra, and Ac-No.

Below the table, the following text is present:

- strong sp-hybridization**: Elements B, C, N, O, F, Ne, Al, Si, P, S, Cl, Ar, Ga, Ge, As, Se, Br, Kr, In, Sn, Sb, Te, I, Xe.
- strong relativistic effects**: Elements Tl, Pb, Bi, Po, At, Rn.

- (*sp*) “Classical” semiconductors – Si, GaAs, ZnS, CIGS
- (*sp*) Ionic “average-valence-4” semiconductors – CsPbI<sub>3</sub>
- (*sp*) Electron-rich semiconductors – P, As, Se, AsSe, GeSbTe
- (*sp*) Electron-poor semiconductors – B
- (*spd*) Transition metal oxides, halides, . . . – TiO<sub>2</sub>, MoO<sub>x</sub>, SrTiO<sub>3</sub>
- (*π*)  $\pi$ -conjugated (organic) semiconductors – graphene, molecules
- (*πd*) Metal-organic frameworks

## Key functional properties of semiconductors

$$\text{Current density} \quad j = \mu \cdot n \cdot e \mathcal{E}$$

- high charge carrier mobility
- controllable charge carrier concentration

# Factors influencing mobility

Current density	$j = \mu \cdot n \cdot e\mathcal{E}$
Mobility	$\nu = \mu \mathcal{E}$
Zero-field mobility	$\mu = \frac{e}{T} D$

Free charge carriers	Localized charge carriers
Drude formula	Hopping
$\mu = \frac{e \tau_{\text{scattering}}}{m_{\text{effective}}}$	$\mu = \frac{2\pi e}{\hbar} f \cdot (aV)^2 \frac{J}{T}$

\* Purely electronic and electron-phonon interaction terms are factorized

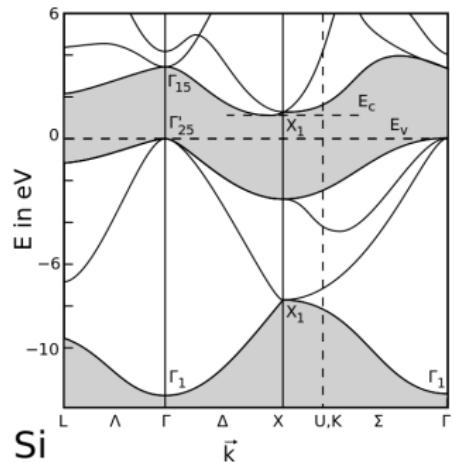
Scattering (or localization) mechanisms:

- dynamic lattice defects (phonons, intramolecular vibrations)
- extrinsic disorder: from lattice defects to mesoscopic inhomogeneity (grain boundaries, interfaces)
- carrier-carrier interaction

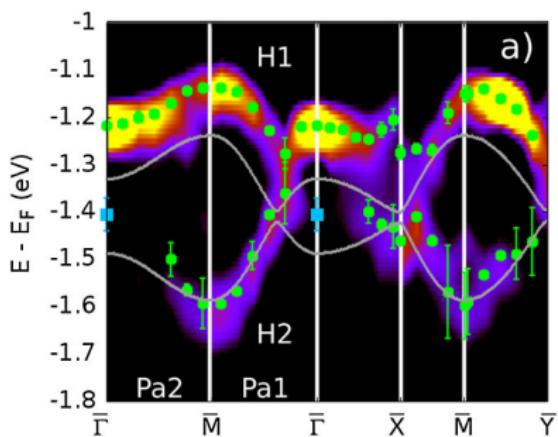
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$f$  is lattice form-factor,  $a$  is lattice spacing,  $V$  is electronic inter-site coupling,  $aV$  is hopping amplitude,  $J$  is spectral overlap

# Need high bandwidth and low effective mass



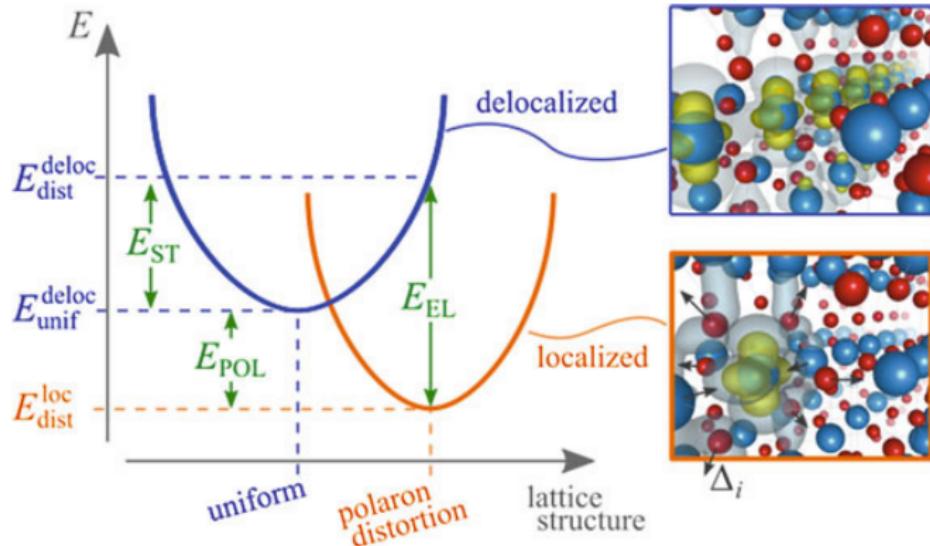
weak e-p interaction  
⇒ free charge carriers  
scattered by phonons



strong e-p interaction  
⇒ mobile or  
localized polarons

# Polarons and localization

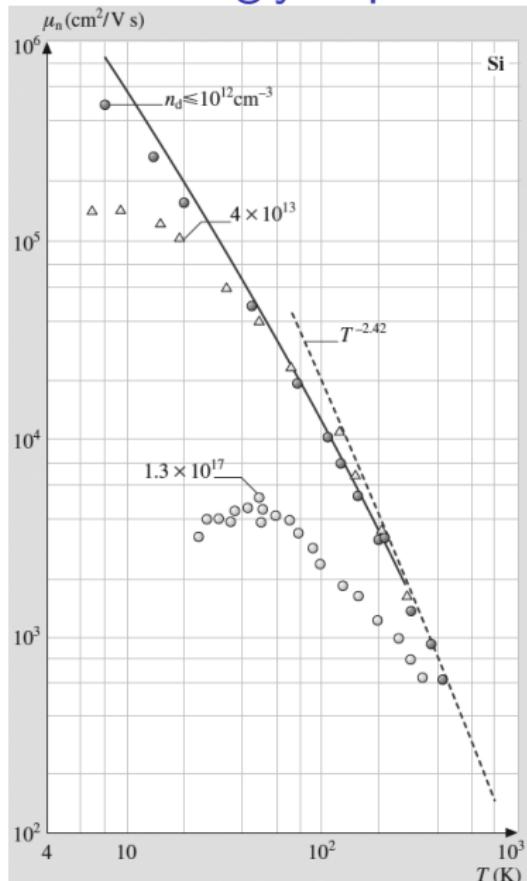
Free charge carriers – large polarons – mobile small polarons – localized charge carriers



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M Reticcioli *et al*, Small Polarons in Transition Metal Oxides (Springer, 2020)

# Scattering by phonons strongly depends on temperature



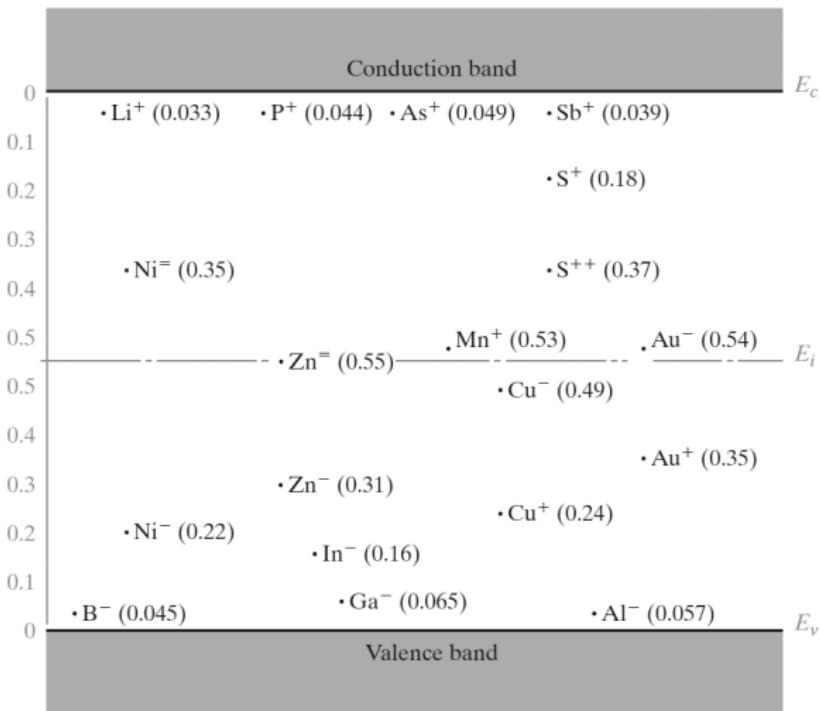
## Room temperature mobility in different semiconductors

material	$\mu_n \left( \frac{\text{cm}^2}{\text{V}\cdot\text{s}} \right)$	$\mu_p \left( \frac{\text{cm}^2}{\text{V}\cdot\text{s}} \right)$
AlGaAs/GaAs 2DEG at low $T$	$10^7$	
graphene at low $T$	$10^5$	
InAs	$10^4$	
Ge	3800	1800
GaAs	3000	400
diamond	2000	2000
monocrystalline Si	1400	400
polycrystalline Si	100	
ZnS	100	40
best organic crystals	10	10
amorphous Si	1	
best organic polymers		0.1
solid electrolytes, water	$10^{-3}$	$10^{-3}$

## Changing charge carrier concentration

- charge carrier injection
- doping (intentional and unintentional)
- photoexcitation
- field effect

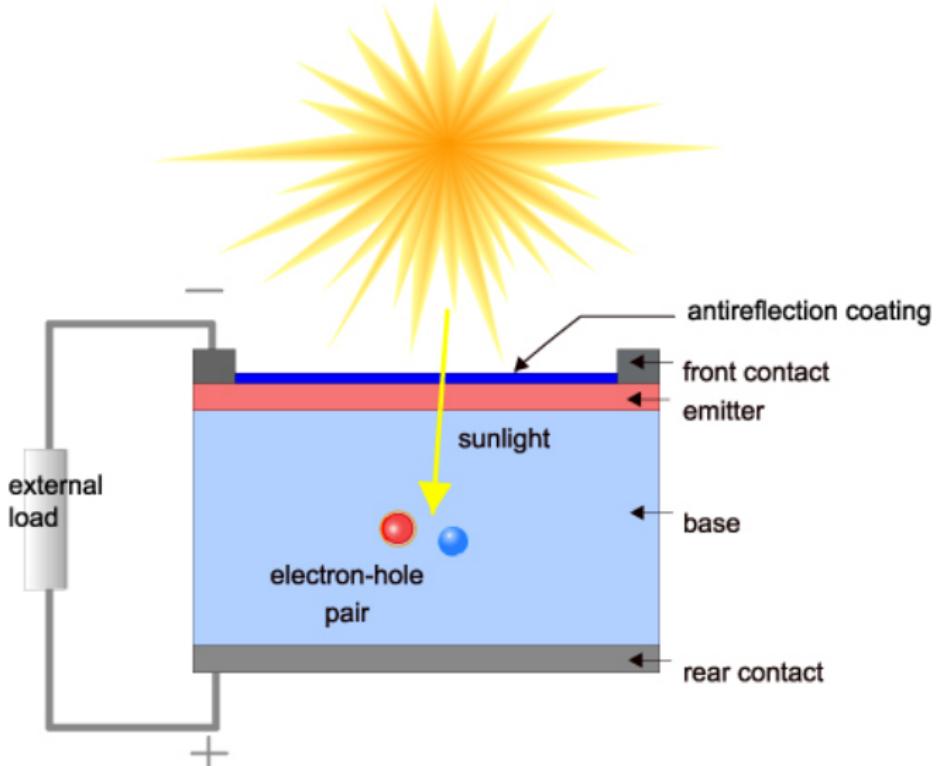
# Doping



**Figure 4–9**  
Energy levels of impurities in Si. The energies are measured from the nearest band edge ( $E_v$  or  $E_c$ ); donor levels are designated by a plus sign and acceptors by a minus sign.

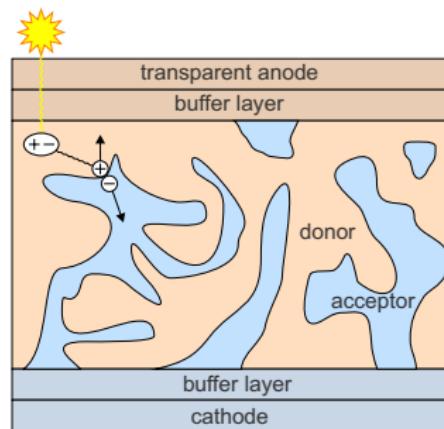
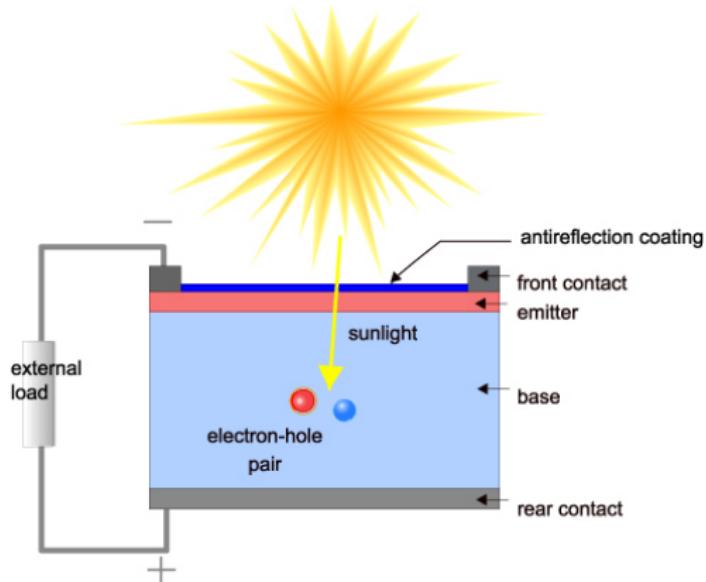
<sup>4</sup>References: S. M. Sze and J. C. Irvin, "Resistivity, Mobility, and Impurity Levels in GaAs, Ge and Si at 300 K," *Solid State Electronics*, vol. 11, pp. 599–602 (June 1968); E. Schibli and A. G. Milnes, "Deep Impurities in Silicon," *Materials Science and Engineering*, vol. 2, pp. 173–180 (1967).

# Photoexcitation



Either bound (Frenkel exciton) or free (or Wannier–Mott exciton)  
electron and holes depending on dielectric constant

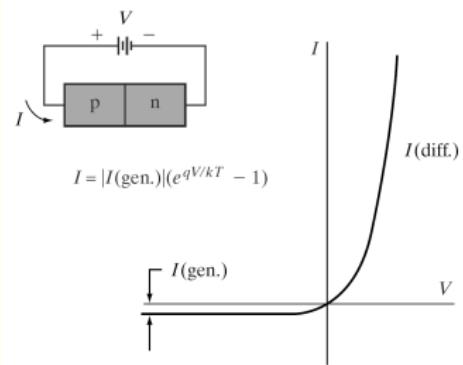
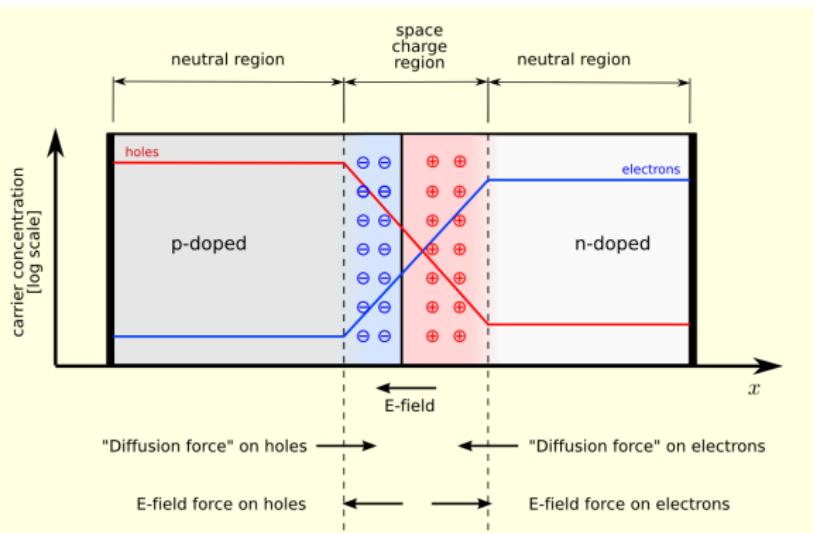
# Photovoltaic effect and solar cells



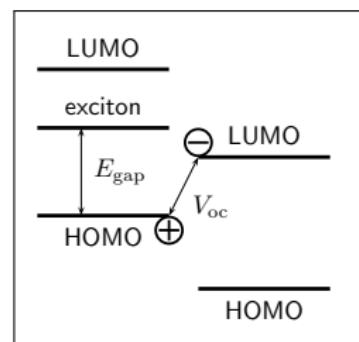
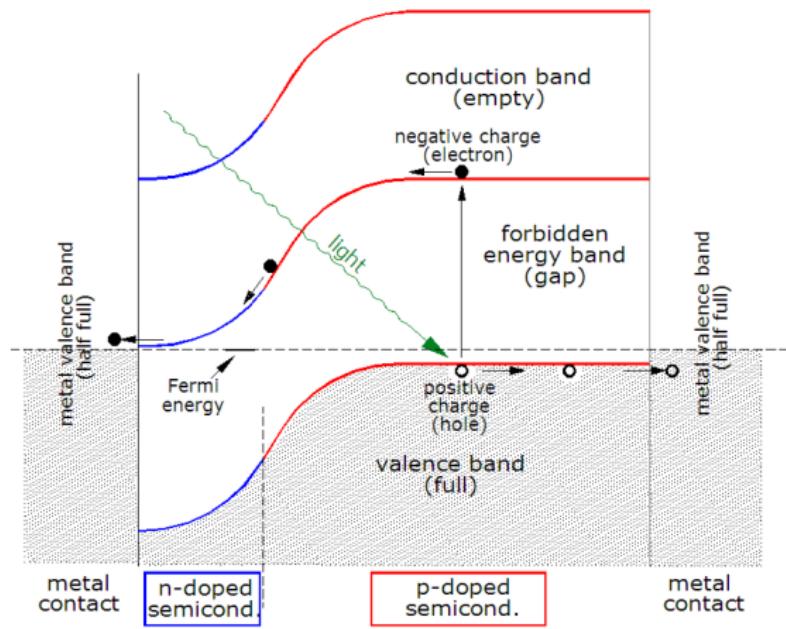
Challenge:

Efficient charge separation at full light absorption and high voltage

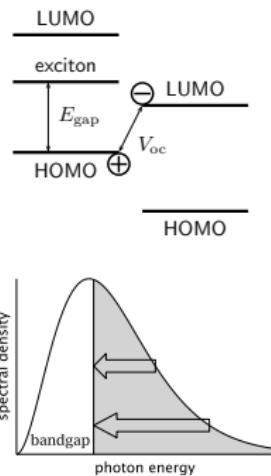
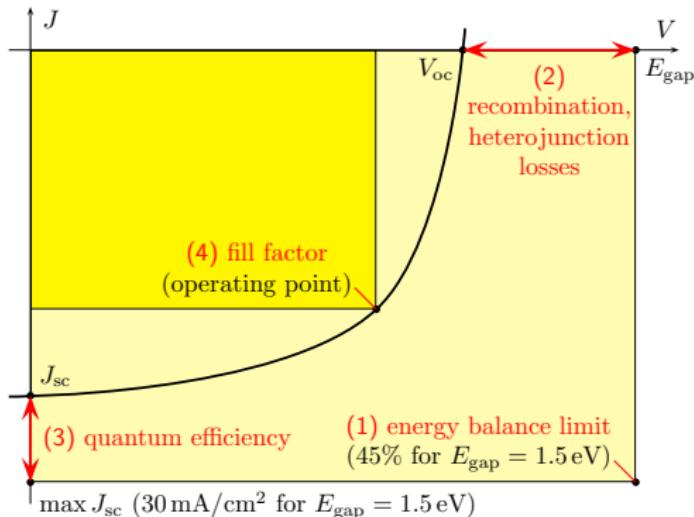
# p-n junction and Shockley diode equation



# Photovoltaic effect: p-n junction and heterojunction



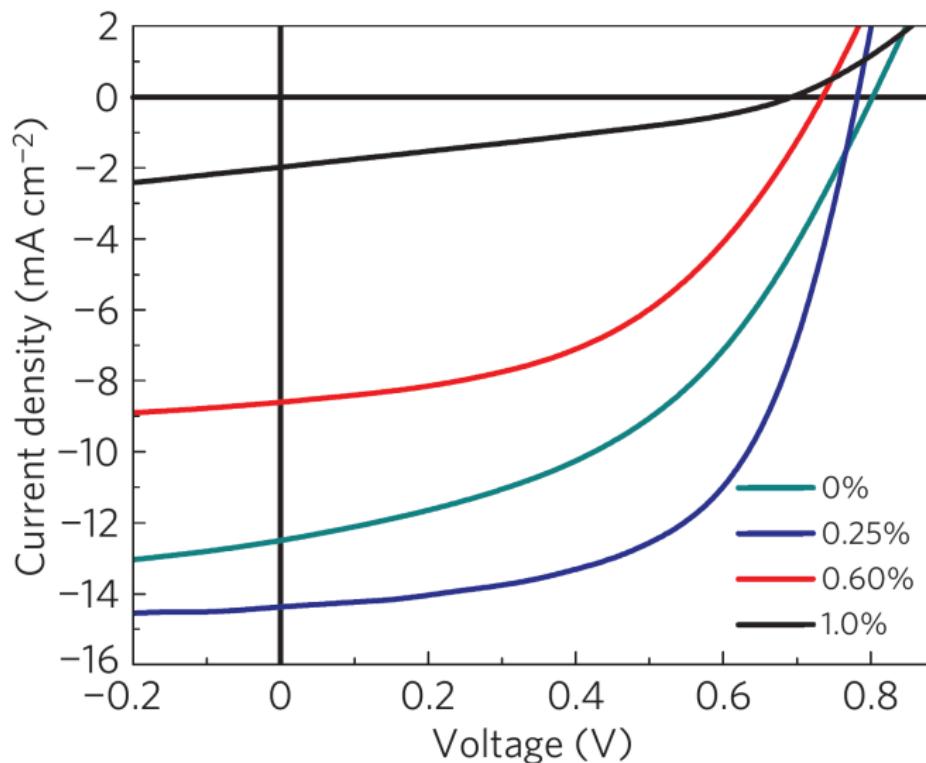
# Power conversion efficiency (PCE): main factors



$$\eta = \frac{J_{sc} \times V_{oc} \times \text{FF}}{P_{in}} \equiv \eta_{abs}(E_g) \times \frac{eV_{oc}}{E_g} \times \frac{J_{sc}}{J_{sc}^{\max}(E_g)} \times \text{FF}$$

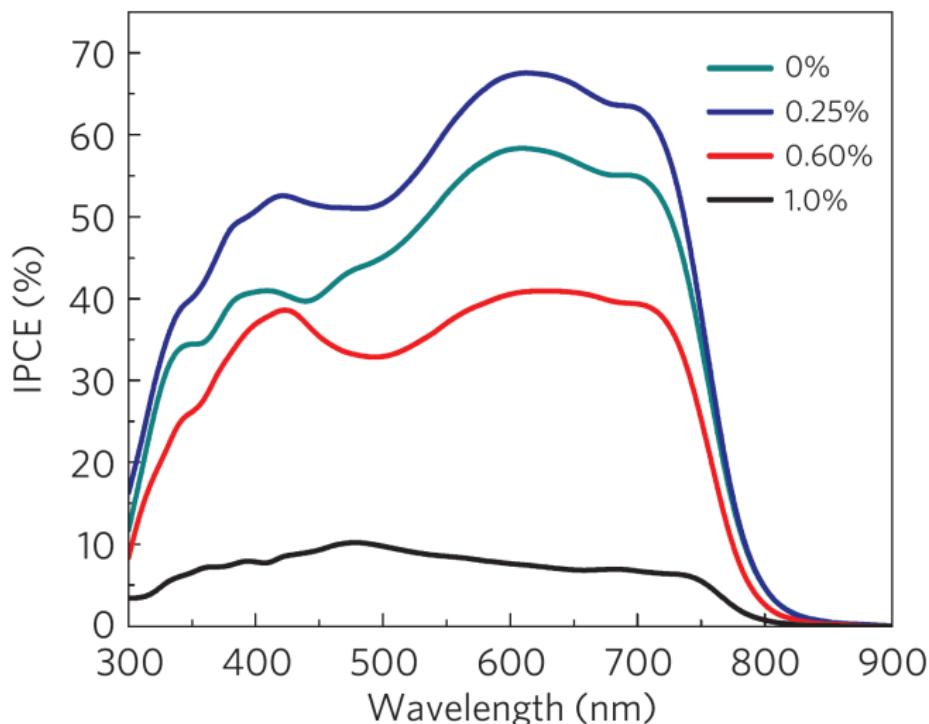
$V_{oc}$  – open-circuit voltage,  $J_{sc}$  – short-circuit current,  $E_g$  – bandgap

## Power conversion efficiency: Fill factor

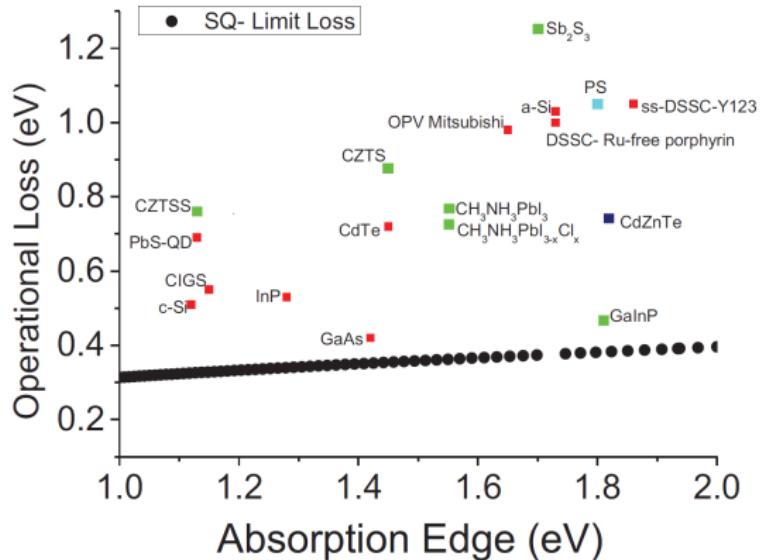
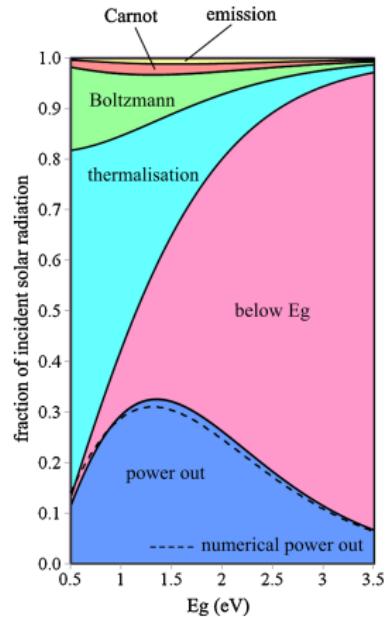


# Power conversion efficiency: Quantum efficiency

(IPCE = Incident Photon to Current Efficiency )



# Power conversion efficiency: Shockley–Queisser limit



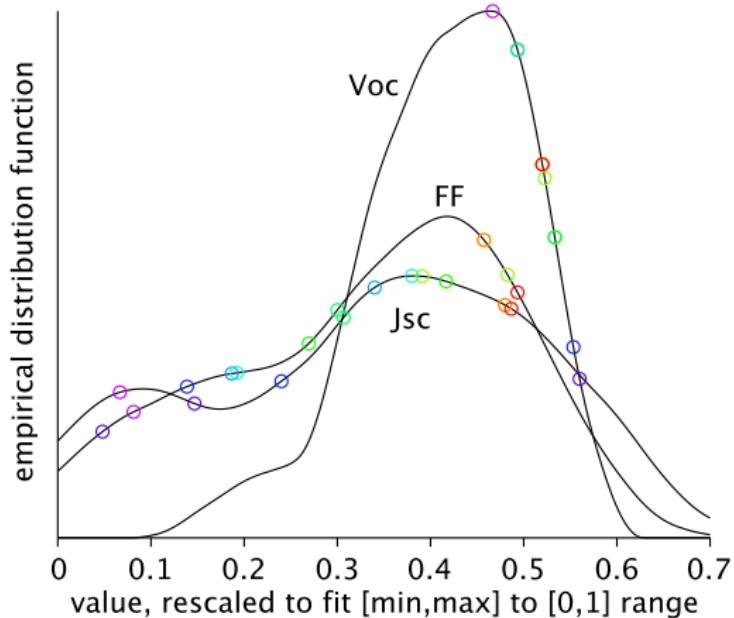
$$eV_{oc} = E_g \left( 1 - \frac{T}{T_{in}} \right) - kT \ln \frac{\Omega_{out}}{\Omega_{in}} + kT \ln \frac{\gamma(E_g, T_{in})}{\gamma(E_g, T)} + kT \ln \eta_{lum}$$

Ref.: J App Phys 32, 510 (1961), Adv Mater 26, 1622 (2014),  
Prog Photovolt Res Appl 19, 286 (2011)

## Power conversion efficiency: examples

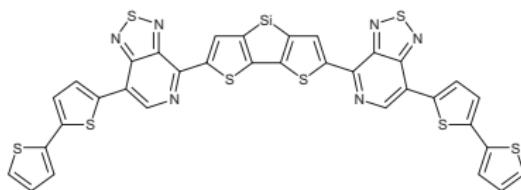
	OPV	Si	GaAs
Energy balance limit, $\eta_{\text{abs}}(E_g)$	0.5	0.49	0.45
Recombination losses, $eV_{\text{oc}}/E_g$	×	0.6	0.63
Quantum efficiency, $J_{\text{sc}}/J_{\text{sc}}^{\max}(E_g)$	×	0.6	0.97
Fill Factor, $\max JV/J_{\text{sc}} V_{\text{oc}}$	×	0.8	0.83
Power conversion efficiency	=	14%	25%
			29%

# Distribution of $V_{oc}$ , $J_{sc}$ , FF

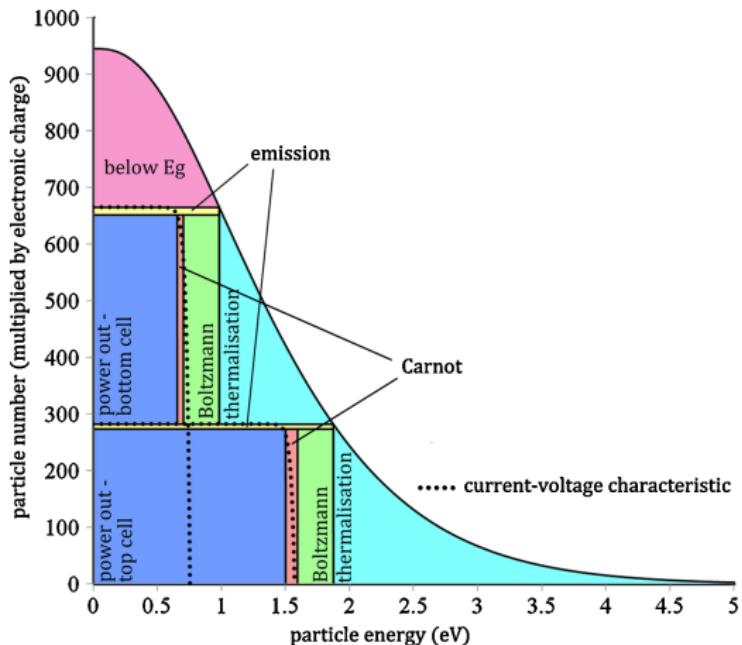
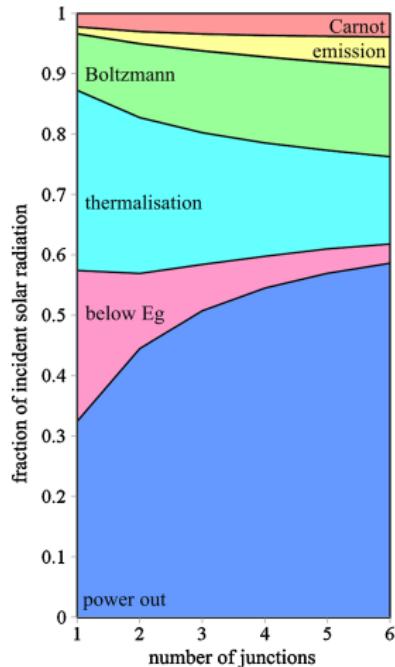


– Empirical distribution over 67 OPVs is provided by J. McClean  
(Clean Energy Project)  
<http://cleanenergy.harvard.edu>

○ Dots correspond to refinement of one system, up to 7% PCE  
(Nature Mater 11, 44 (2012)  
JACS 134, 16597 (2012))

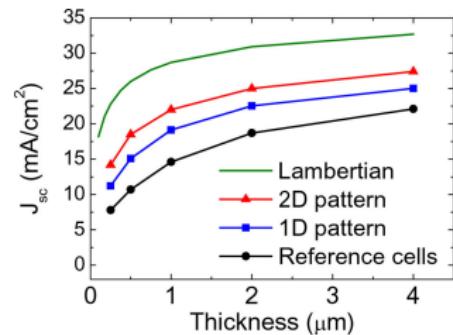
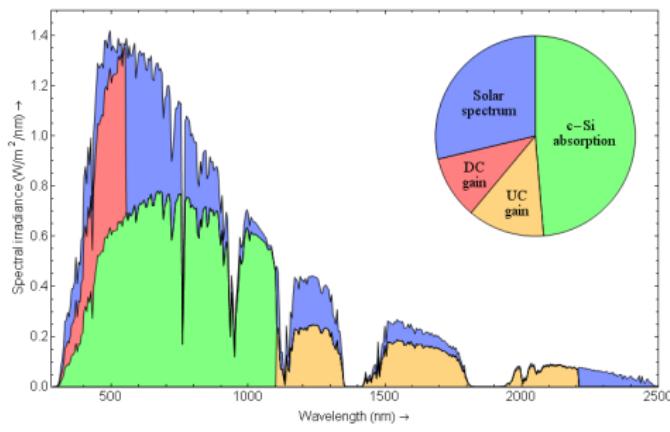
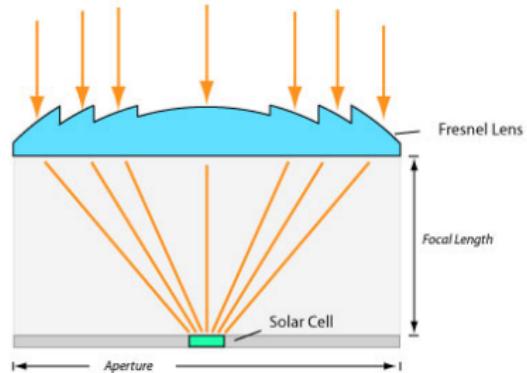
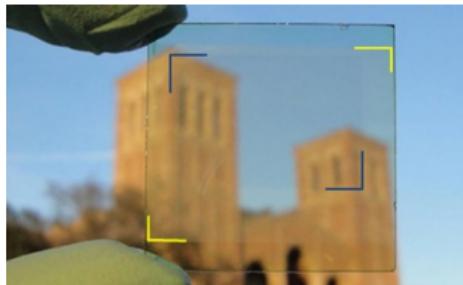


# Multijunction cells

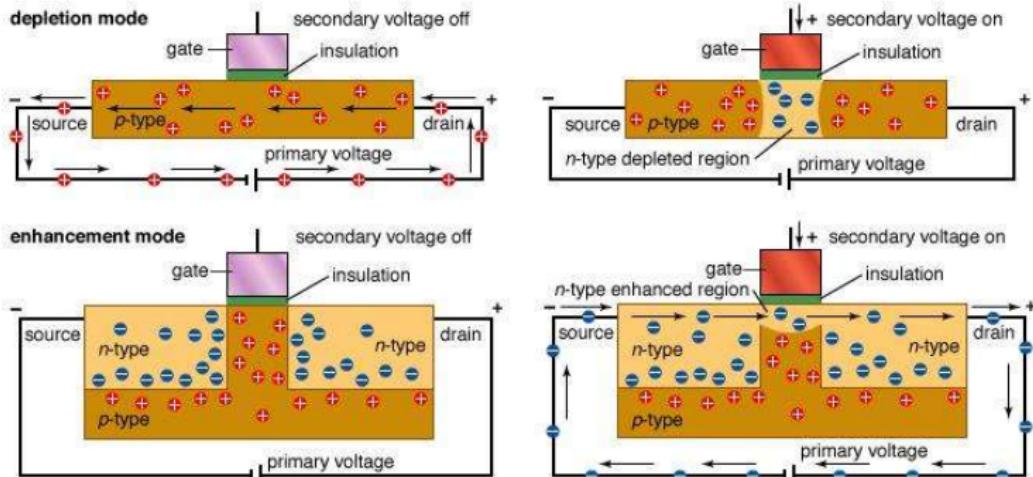


# Technology: other tricks

(transparent, concentrated, up-down conversion, improved optics)



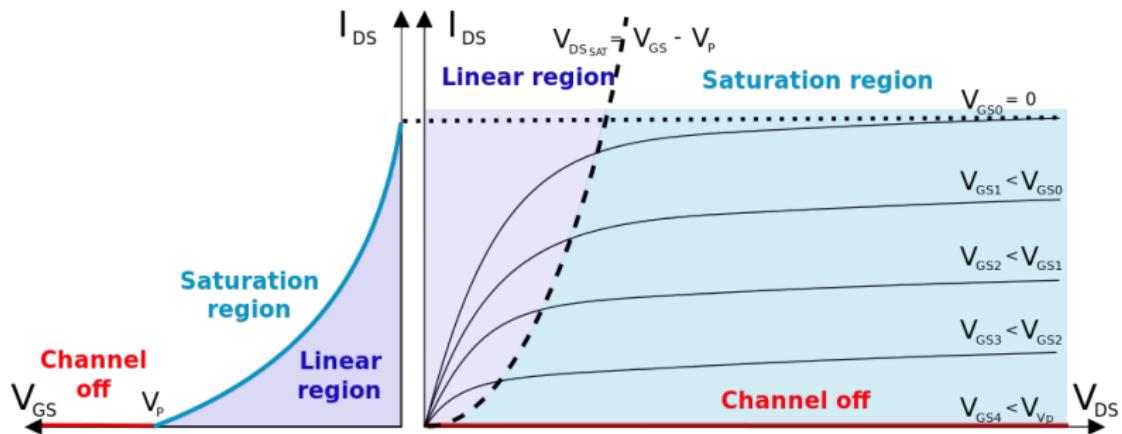
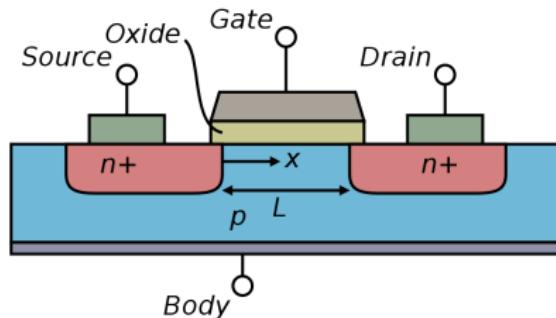
# Field effect



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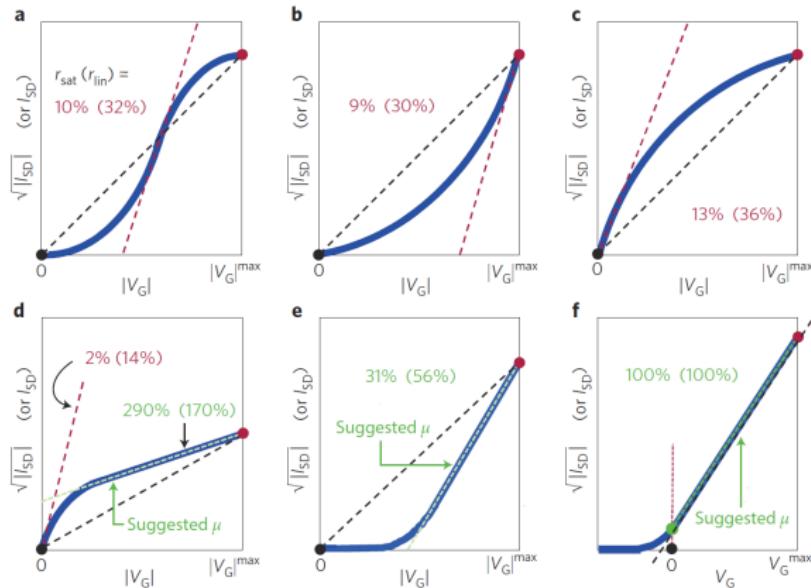
# Field effect transistor

(depletion mode)



# Field effect transistor: measuring mobility

H H Choi, K Cho, C D Frisbie, H Sirringhaus, V Podzorov, Nat Mater 17, 2 (2018) – pdf



In linear regime  $\mu = \frac{L/W}{CV_{SD}} \frac{dI_{SD}}{dV_G}$ , where  $L/W$  is channel form-factor (length/width) and  $C$  is gate-channel capacitance per unit area<sup>1</sup>

<sup>1</sup>Should be measured, if not possible, estimate as  $\epsilon\epsilon_0/d$

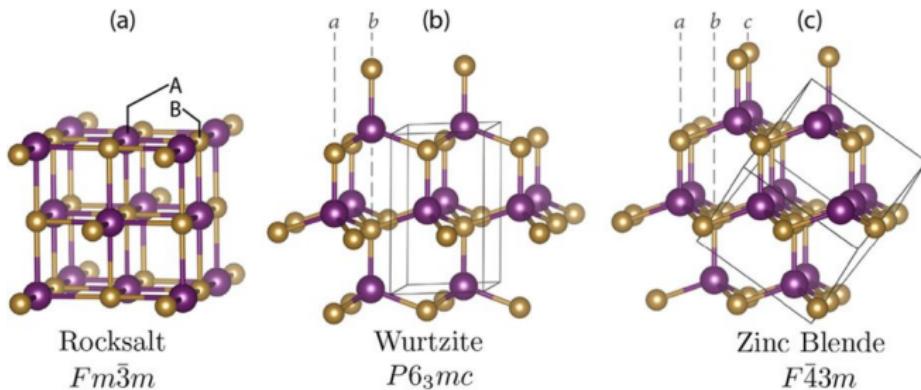
## Other functional properties of semiconductors

- high charge carrier mobility
- controllable charge carrier concentration
- FET: high saturation velocity
- FET: high on/off ratio
- Solar/PD: strong light absorption (high IPCE)
- LED: efficient light emission (high EQE)
- Solar/LED: right bandgap (or use dopants)

# “Classical” semiconductors

Average valence 4 compounds:

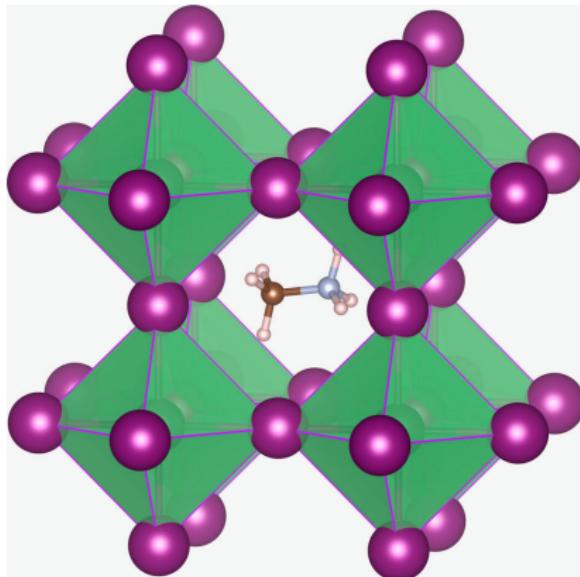
- IV (Si)
- III+V (GaAs)
- II+VI (ZnS)
- I+VII (AgI)
- II+IV+V ( $\text{CdSnAs}_2$ )
- I+III+VI ( $\text{CIGS} = \text{CuIn}_{1-x}\text{Ga}_x\text{Se}_2$ )



- Prefer mostly tetrahedral lattices: zincblende or wurtzite
- Wide-gap ionic compounds might form rocksalt lattice
- Also heterostructures and nanostructures

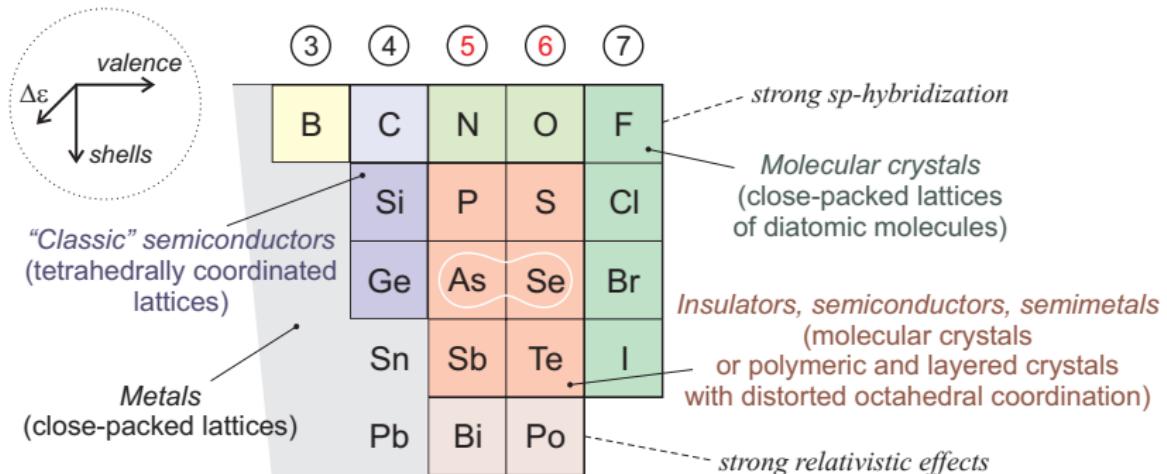
# Ionic “average-valence-4” semiconductors

Semiconducting halide perovskites: I+II+VII or ABX<sub>3</sub>



Ionic  $\implies$  solution processable

# Pnictide and chalcogenide semiconductors



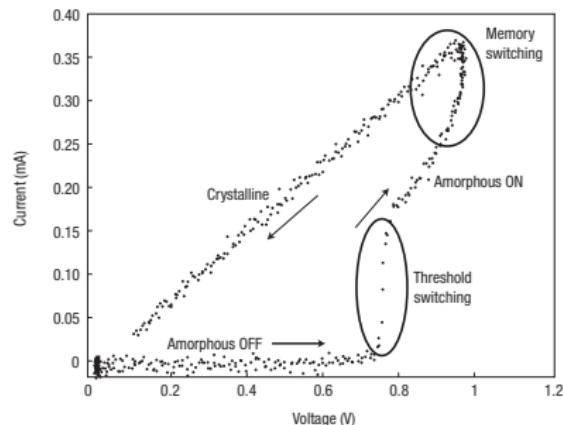
- Pnictogens: P, As, Sb
- Chalcogens: S, Se, Te
- Average valence 5-6
- Not in the class: transition metal pnictides and chalcogenides

## Key properties

- Polymorphism with high contrast in electronic properties:  
*crystalline As is metal, amorphous As is insulator*
- Photo- and current-induced reversible structural changes:  
*phase change memory alloys*
- Low covalent connectivity (2-3), strong noncovalent bonding  
*1D, 2D, and “sandwich” structures, nonstoichiometric alloys*

# Application: Phase change memory

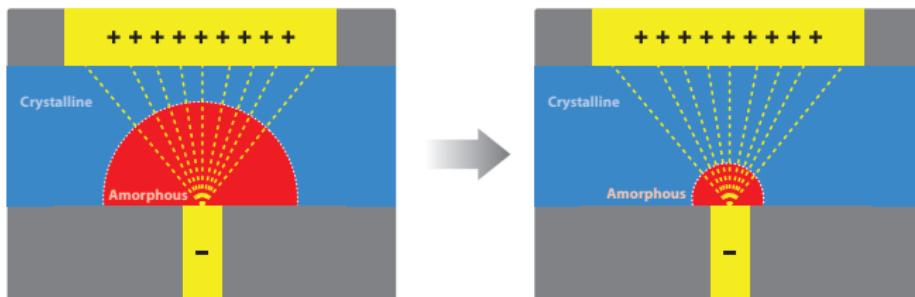
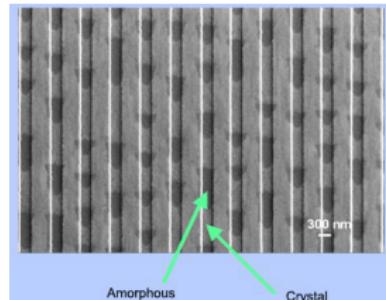
Polymorphism with high contrast in electronic properties  
+ fast transition between the two phases



- DVD-RAM and DVD-RW
- PCM or PRAM  
non-volatile random-access  
memory

Nature Mater 6, 824 (2007)

# Phase change memory: historical perspective

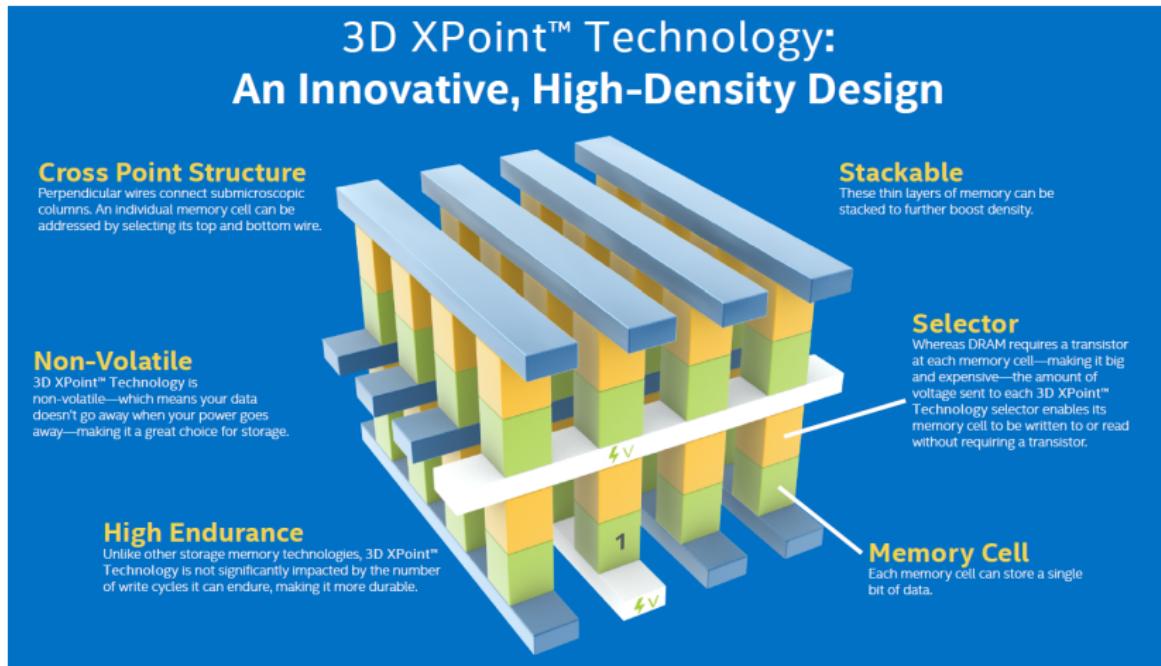


Phase change memory (PCM, PRAM) – 60-year evolution:

- 1) research  $\implies$  reviews 1955, patent 1966, DVD 1997
- 2) research  $\implies$  reviews 2000s, PRAM prototypes 2005

# Phase change memory: engineering perspective

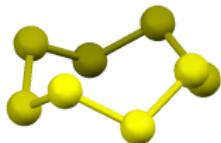
## 3D XPoint non-volatile memory (2015)



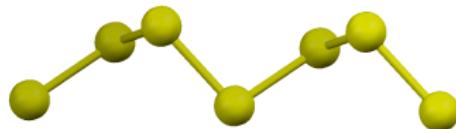
## Examples and applications summary

- $\text{Ge}_2\text{Sb}_2\text{Te}_5$  and  $\text{AgInSbTe}$  – phase-change materials
- materials for “3D carving” for photonics and optoelectronics
- $\text{Se}$  was commonly used as photoconductor in photocopiers
- $\text{Bi}_2\text{Te}_3$  – one of the best performing thermoelectrics  
(strictly speaking not in the class)

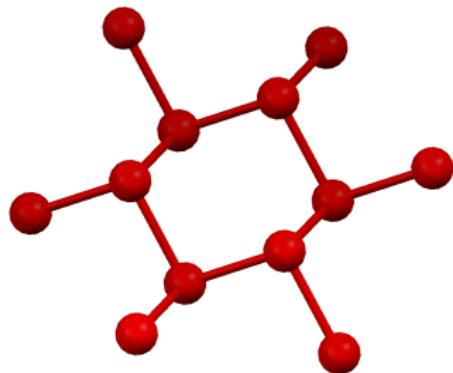
## Structure: diversity and polymorphism



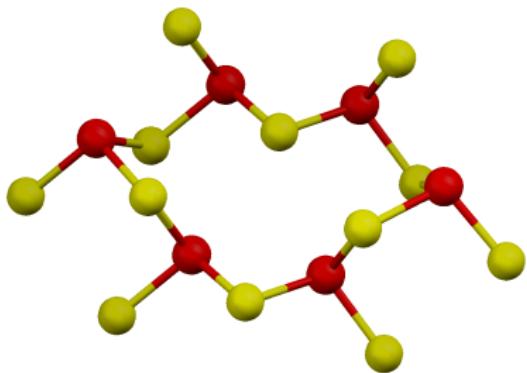
$\alpha\text{-S}$   
(molecular crystal)



Se, Te, high-pressure S  
(polymeric crystal)



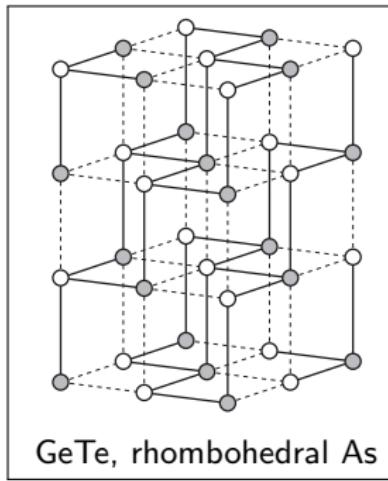
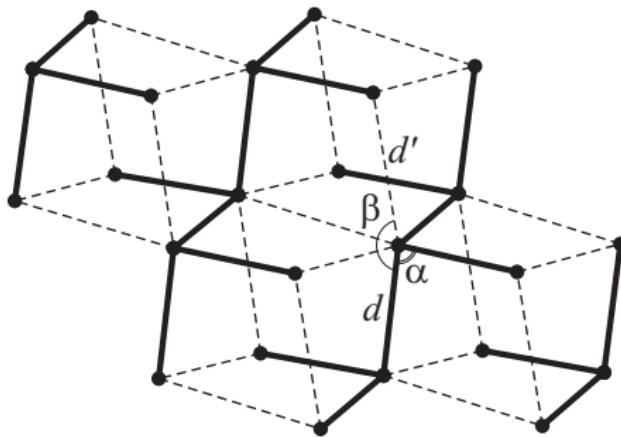
As, Sb, Bi, high-pressure P  
(layered crystal)



$\text{As}_2\text{S}_3$   
(layered crystal)

Is there a common structural motif?

## Structural motif: distorted octahedral coordination

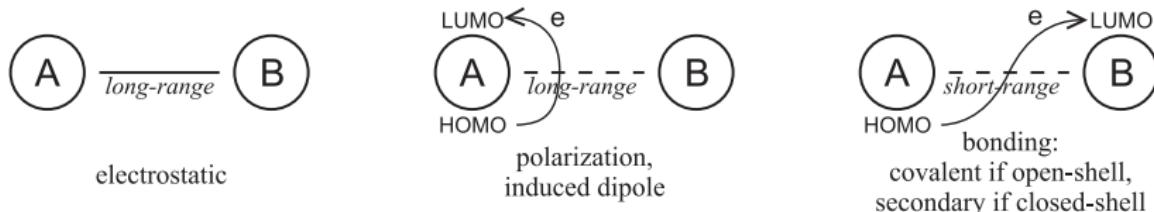


- Right-angled geometry:  $90^\circ \lesssim \alpha < 109^\circ$
- Secondary  $p\sigma p\sigma$  bonding:  $d'_{AB} < r_A^{\text{vdW}} + r_B^{\text{vdW}}$
- Can be called “back-bonding”:  $\beta > 160^\circ$
- Trans-influence:  $d_{AB} > r_A^{\text{cov}} + r_B^{\text{cov}}$

But

- some bonds may be missing for elements of group VI and VII
- competing tetrahedral coordination for elements of group IV

# What is secondary bonding?



$$\begin{aligned} E_{\text{bind}} &= \Delta E_{\text{nuc}} + \langle AB | H_{\text{int}} | AB \rangle \\ &\quad + \sum_{\text{exc}} \frac{\langle AB | H_{\text{int}} | A^{\text{exc}} B^{\text{exc}} \rangle^2}{E_A + E_B - E_A^{\text{exc}} - E_B^{\text{exc}}} \\ &\quad + \sum_{\pm \text{states}} \frac{\langle AB | H_{\text{int}} | A^\pm B^\mp \rangle^2}{E_A + E_B - E_A^\pm - E_B^\mp} \\ \implies E_{\text{sec.bond}} &= \frac{2t_{12}^2}{E_1^{\text{ion}} - E_2^{\text{aff}}} \equiv \frac{E_1^{\text{ion}} - E_2^{\text{aff}}}{2} \times \langle \text{bond-order} \rangle \end{aligned}$$

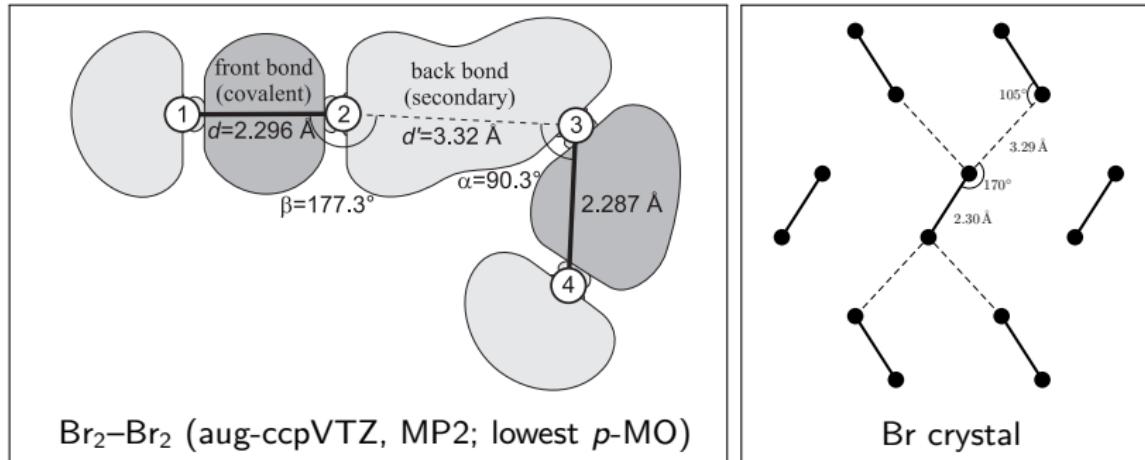
# Examples of secondary bonding

Structural signatures of secondary bonding:

- Orbital overlap:  $d'_{AB} < r_A^{\text{vdW}} + r_B^{\text{vdW}}$
- Trans-influence:  $d_{AB} > r_A^{\text{cov}} + r_B^{\text{cov}}$
- Alignment with respect to the covalent bond

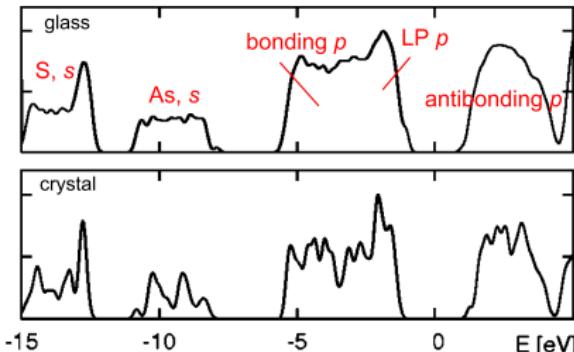
		donor	acceptor	$t'$	$E^{\text{ion}} - E^{\text{aff}}$
backbonding	$\alpha\text{-As}$	$pp\sigma$	$pp\sigma^*$	$t'_{pp\sigma}$	$2t_{pp\sigma}$
backbonding	$\text{Br}_2\text{-Br}_2$	$pp\sigma$	$p\text{-LP}$	$t'_{pp\sigma}$	$t_{pp\sigma}$
$\pi$ -conjugation	poly-CH	$pp\pi$	$pp\pi^*$	$t'_{pp\pi}$	$2t_{pp\pi}$
$\pi$ -backbonding	$\text{Cr}(\text{CO})_6$	$pp\pi$	$d$	$t'_{pp\pi}$	$t_{pp\pi} + \Delta\varepsilon_{pd}$
	$\text{Be}_2$	$s$	$p$	$t_{sp}$	$\Delta\varepsilon_{sp}$
hydrogen bond	H-A	$s$	A		
halogen bond	F-D	D	$p$		

## Examples of secondary bonding: halogen molecules

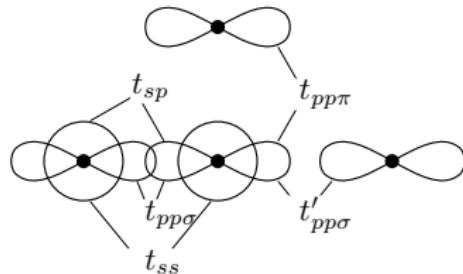


- Right-angled coordination:  $\alpha \approx 90^\circ$
- Secondary bonding:  $d' < 2r_{vdW}$  and  $\beta \approx 180^\circ$
- Trans-influence:  $d > 2r_{cov}$  (left molecule is elongated)
- Dimer and crystal have principally the same geometry

# Electronic structure: degeneracy of the covalent network



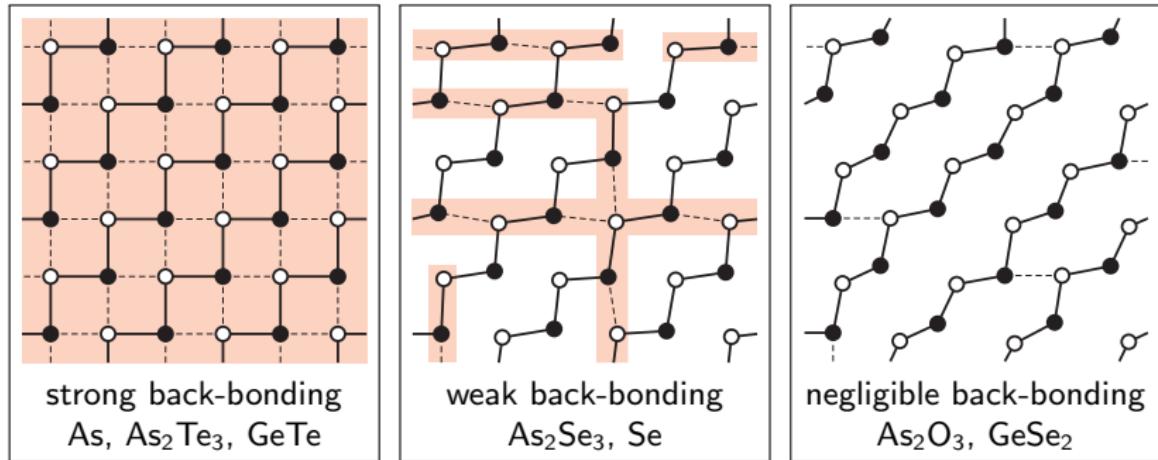
EDOS for  $\text{As}_2\text{S}_3$  (Simdyankin, Elliott, 2004)



Transfer integrals

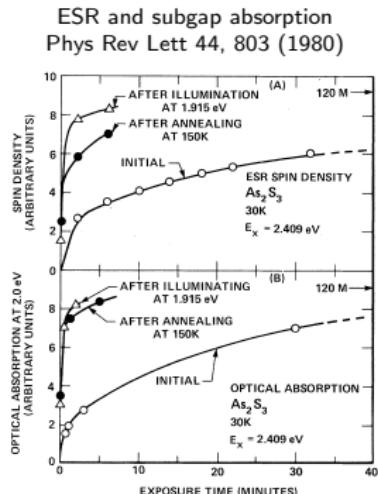
- $s$ -orbitals do not contribute to bonding
  - it is the network of  $pp\sigma$ -bonds ( $pp\sigma$ -network)
- $pp\sigma$ -bonds themselves do not form 3D solid
  - the structure is determined by the balance of
    - secondary bonding  $t_{pp\sigma}'^2 / 2t_{pp\sigma}$
    - hybridization or  $sp$ -interaction  $t_{sp}^2 / (\varepsilon_p - \varepsilon_s - t_{pp\sigma})$
    - $pp\pi$ -interaction (usually small)  $t_{pp\pi}^2 / 2t_{pp\sigma}$

## Structure: three classes of $pp\sigma$ -networks

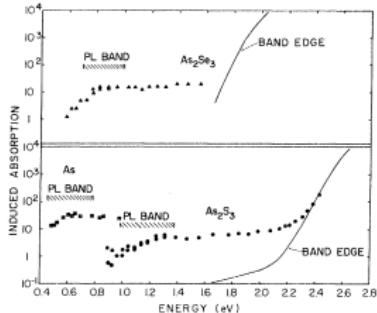


How to get this picture: Project Fock matrix onto valence  $p$ -orbitals and mark all the resulting elements  $\gtrsim 0.5t_{pp\sigma}$

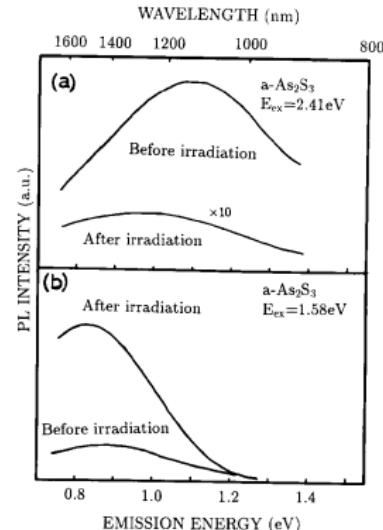
# Photoinduced phenomena: experiment



Midgap absorption  
Phys Rev B 15, 2278 (1977)

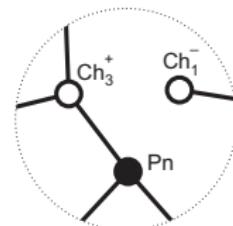
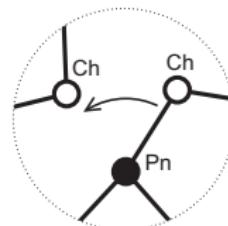
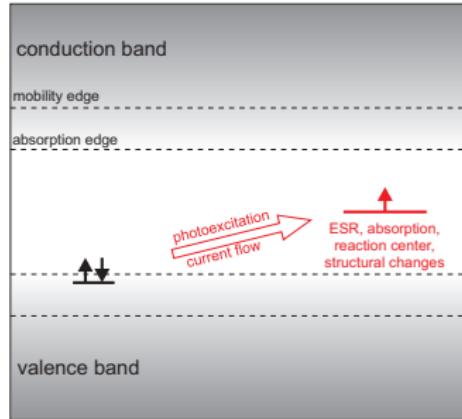


New PL after bandgap irradiation  
J Non-Cryst Solids 114, 88 (1989)



- 5% volume expansion [J Optoelectronics Adv Mater 8, 2058 (2006)]

# Photoinduced phenomena: theory



1. Midgap states originate from coordination defects whose ground state is charged (Street, Mott, 1975)
2. They pair up into positively charged overcoordinated atom and negatively charged undercoordinated – VAP (Kastner, Adler, Fritzsch, 1976; Pollard, Joannopoulos, 1979)
3. Defects can move and be created by bond switching, which is the underlying mechanism for photoinduced phenomena

What is the microscopic mechanism for such an efficient bond switching?

## Challenges

- Find better materials for phase change memory
- Improve device architecture for phase change memory
- How to drive structural changes nonthermally
- Lack of microscopic description of photoinduced changes
- Lack of quantitative prediction of photoinduced changes
- Limited use of pnictides and chalcogenides

# Research at Skoltech

## Theory:

- **Vasili Perebeinos** (now at Buffalo U) – classical semiconductors
- **Xavier Gonze** (also at UCLouvain) – classical semiconductors
- **Sergei Tretiak** (also at LANL) – perovskites, organic, quantum dots
- **Sergey Levchenko** – oxides
- **Andriy Zhugayevych** – organic, pnictides/chalcogenides

## Experiment:

- **Keith Stevenson** – organic, perovskites
- **Pavel Troshin** (now at IPCP RAS) – organic, perovskites
- **Albert Nasibulin** – carbon nanotubes
- **CPQM CREI** – photonics and optoelectronics

# Resources

- Wikipedia
- Callister chapter 18.(1-15)
- Ashcroft chapters 28-29
- Kittel chapter 8
- Textbooks (see Topical references on semiconductors)
- Perovskites: [References](#)
- Pnictides/chalcogenides: [References](#)
- Organic: [References](#)
  - ▶ Separate lecture [here](#)
  - ▶ Separate course in Term 3
  - ▶ A Koehler, H Bassler, Electronic Processes in Organic Semiconductors: An Introduction (Wiley, 2015) *in library*
  - ▶ Albert Nasibulin's lecture on carbon nanotubes in Canvas